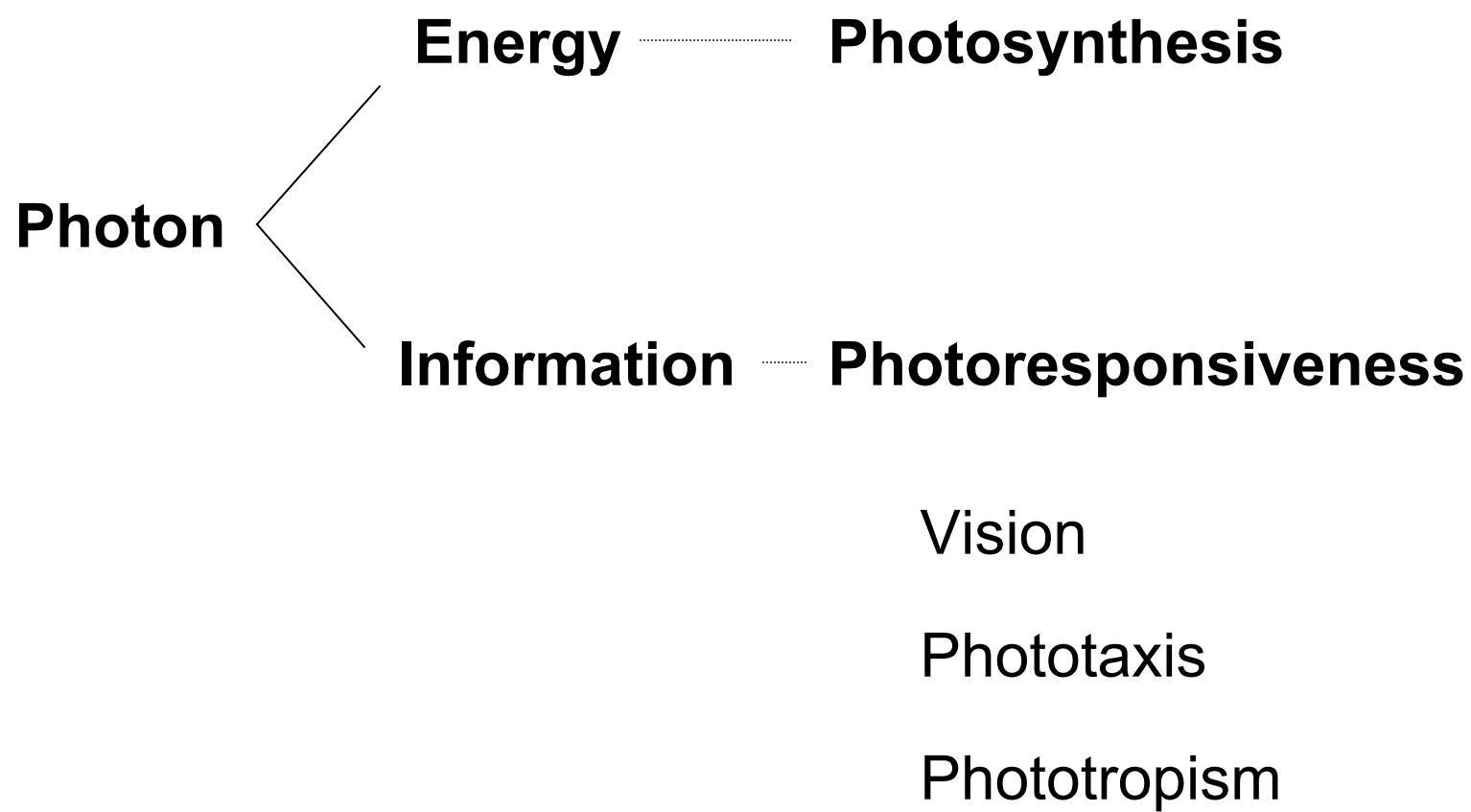


# **Photochromism**

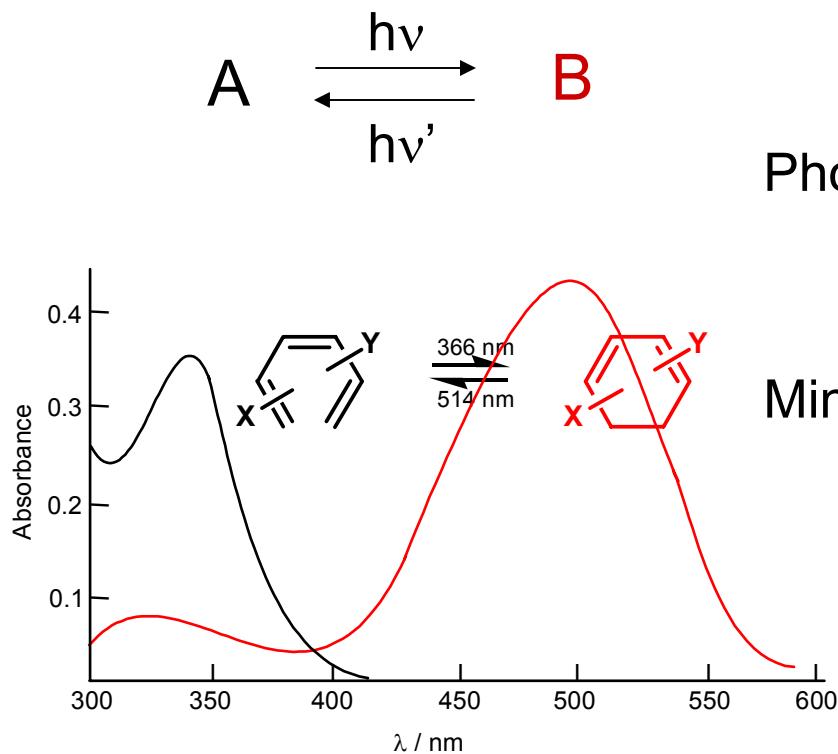
## **- Fundamentals and Applications -**

Masahiro Irie

Department of Chemistry and Biochemistry  
Kyushu University, Fukuoka, Japan



# Photochromism



Natural

Photoreceptor : Rhodopsin (Chlamydomonas)

Bacteriorhodopsin

Phytochrome

Sodalite

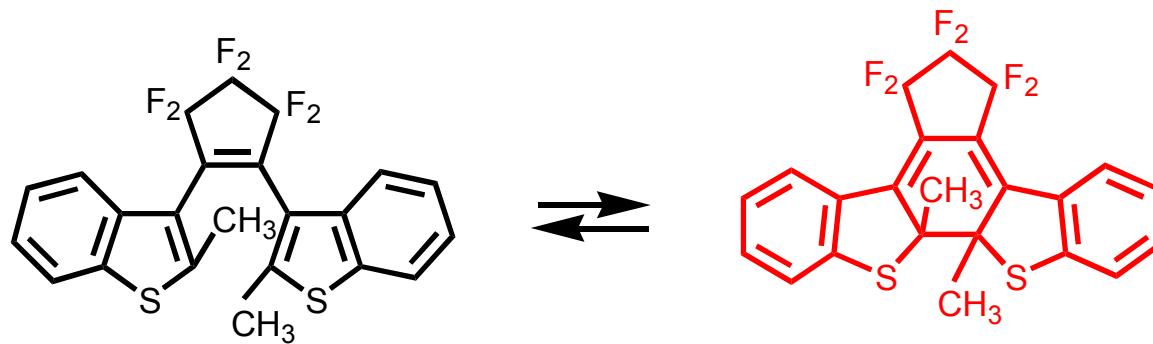
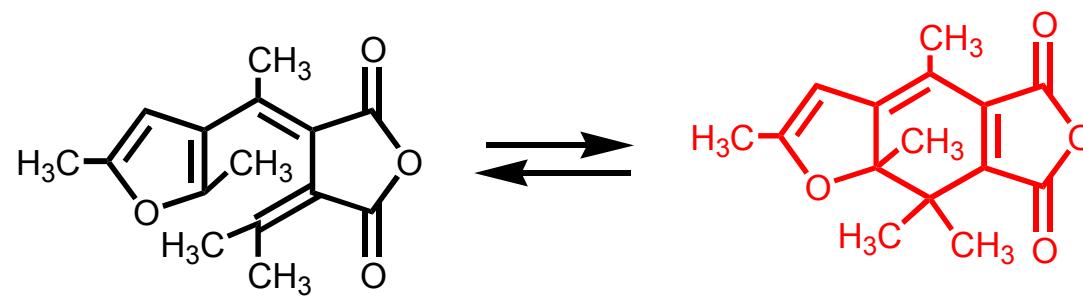
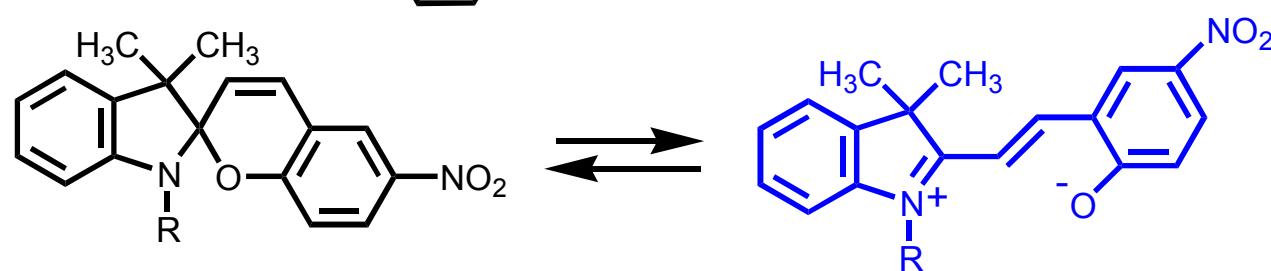
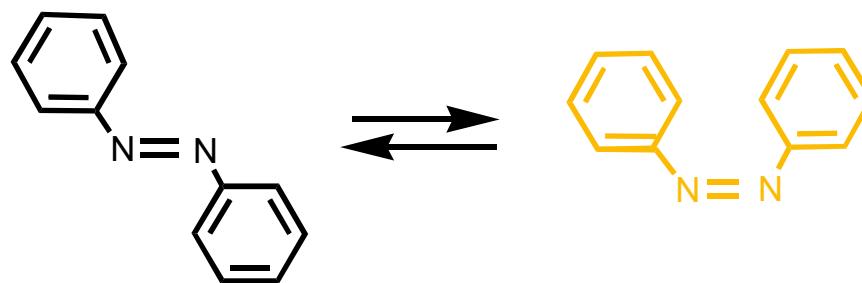
Mineral :

Artificial

Dyes : Spirobenzopyran,  
Azobenzene . . .

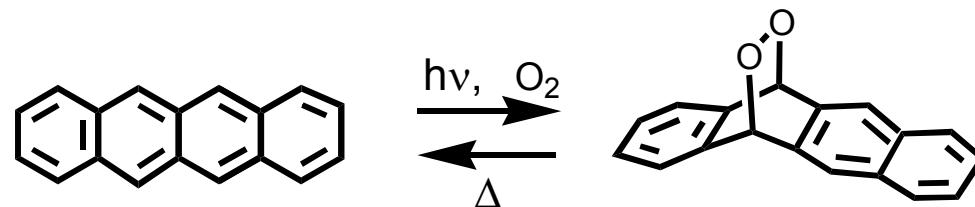
Metal-oxide Glass

Chalcogenide Glass

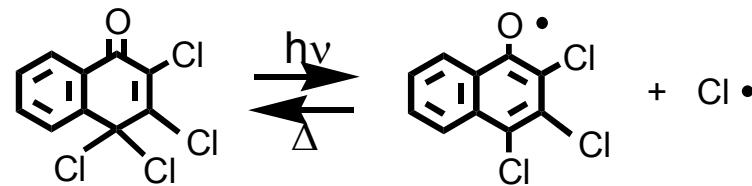


## Brief History of Photochromism

1867 M. Fritsche

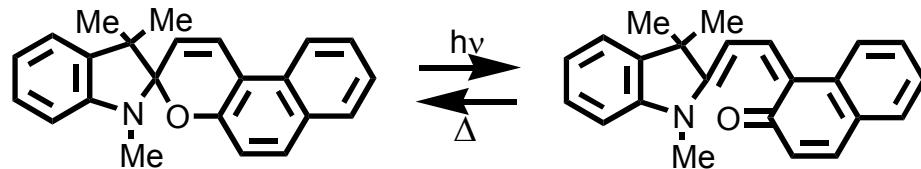


1899 W. Marckwald



(G. Scheibe et al. J. Phys. Chem. **66**, 2449 (1962))

1952 E. Fischer, Y. Hirsberg



(J. Chem. Soc., 4522 (1952))

Self-developing, Dry Photographic Systems

High-speed Printing Materials

Chemical Computer

Camouflage Fabrics

N C R (Spiropyran)

R C A (Indigos)

American Cyanamid (Spiropyrans, Metal Dithizonates)

EG & G (Triarylmethane Leuco Derivatives)

Fuji Film (Spiropyrans)

1970 ~ 1980

## Dark Ages

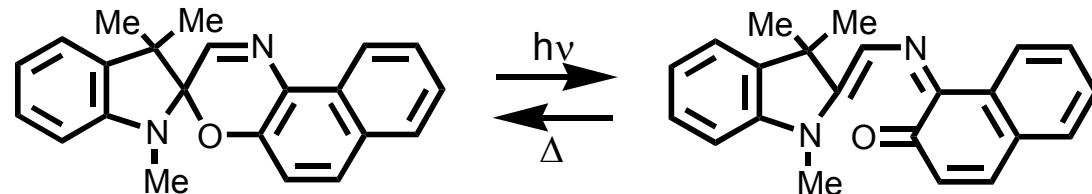
Lack of fatigue resistant characteristics  
(photo-degradation)

"Photochromism" G. Brown Ed.

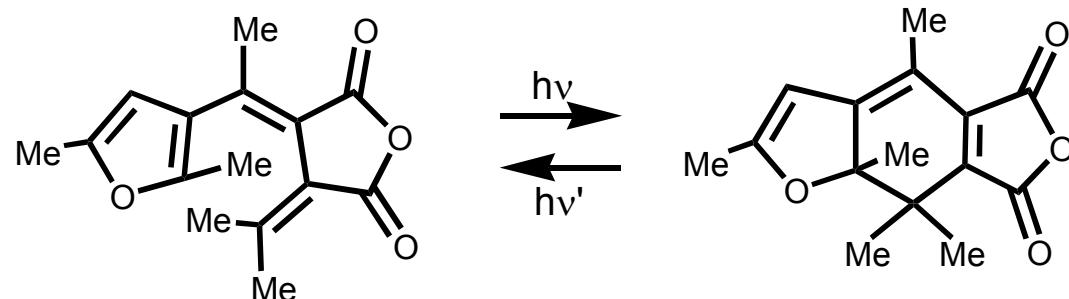
1980 ~ Present

## Renaissance

Fatigue Resistant Spironaphthoxazine



Thermally Irreversible Compounds



Name	Reaction
Azobenzene	
Spirobenzopyran	
Naphthopyran	
Thioindigo	
Anthracene Dimer	
Dihydroazulene	

---

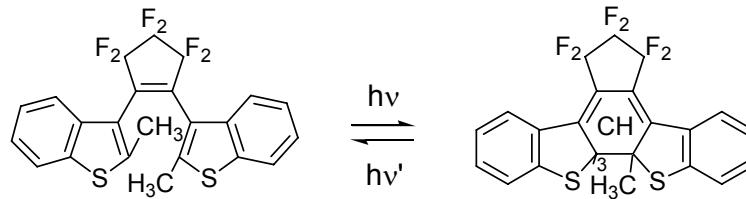
Name

---

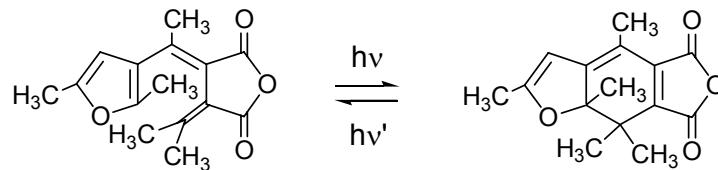
Reaction

---

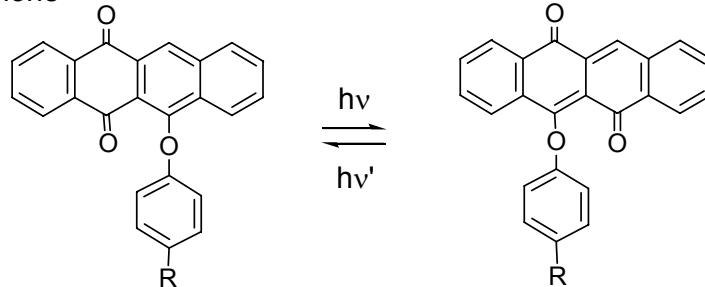
Diarylethene



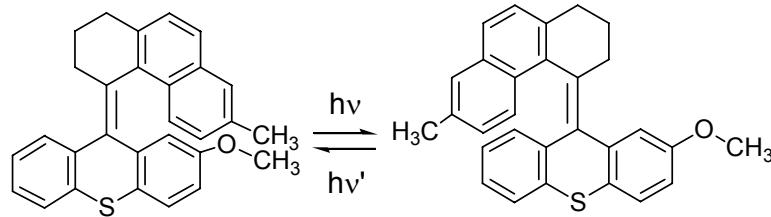
Furyl Fulgide



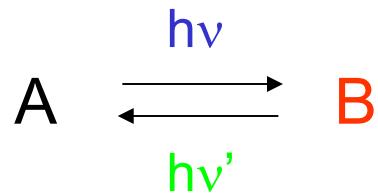
Naphthacene quinone



Stilbene Derivative



## Requirements for Photonics Devices

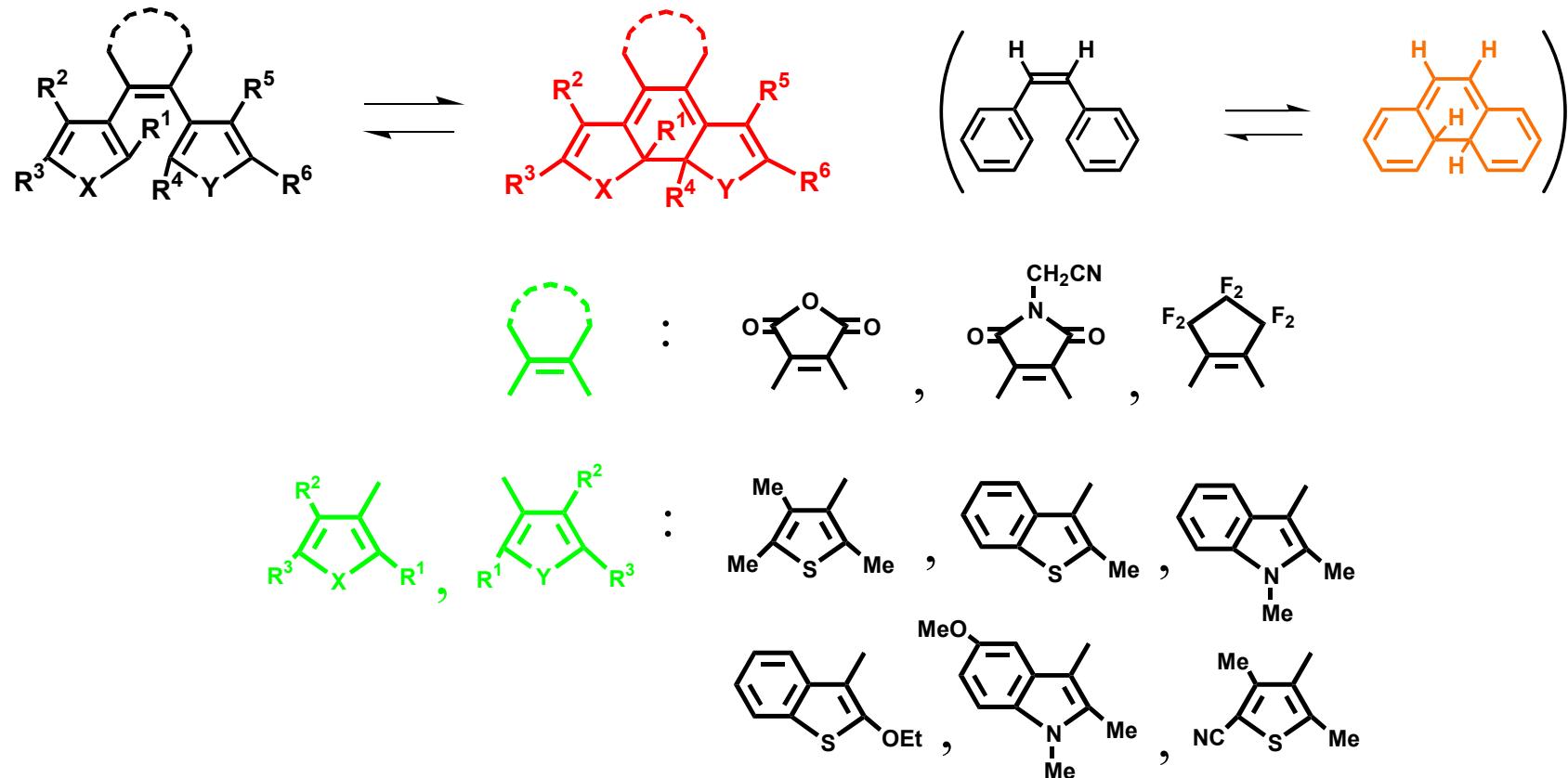


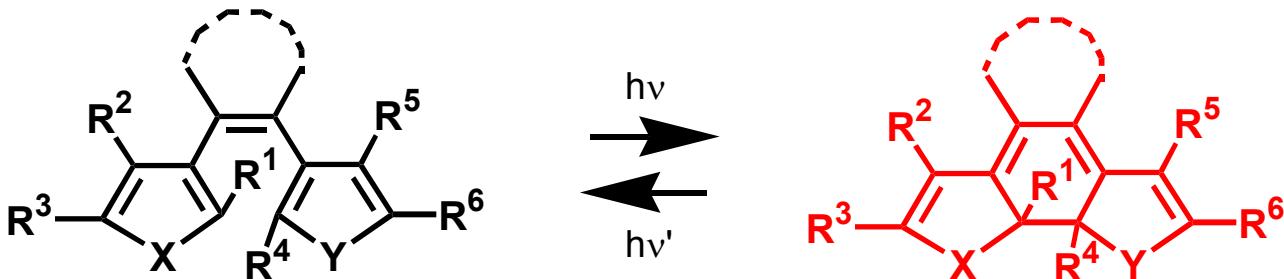
1. *Thermal stability of both isomers*
2. *Fatigue resistant character:*  
repeatable cycle number  $> 10^4$
3. *High sensitivity:*  
quantum yield  $> 0.5$
4. *Rapid response*
5. *Reactivity in the solid state*

# A New Class of Photochromic Compounds

— Thermally Irreversible and Fatigue Resistant —

— Diarylethenes —





- Both isomers are thermally stable

long term stability :

470,000 years at 30 ° C

short term stability : 150 ° C

- Low fatigue

repeatable cycle number :  $10^5$

- High sensitivity

quantum yield : 0.1 -  
1.0

- Rapid response

$< 10^{-11}$  sec

- Reactivity in the crystalline phase

- Sensitivity at visible region

forward reaction : 488 nm

backward reaction : 780 nm

# **Molecular Design of Diarylethenes**

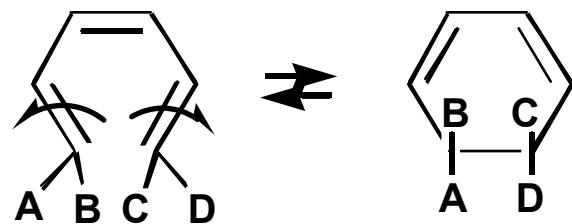
Thermal Stability

Fatigue Resistant Character

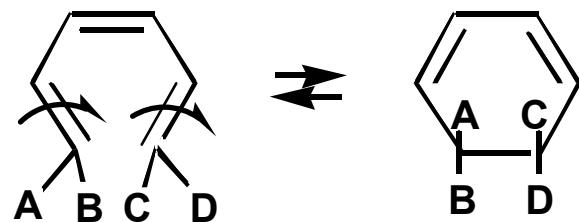
Response Time

## Molecular Orbital Calculation

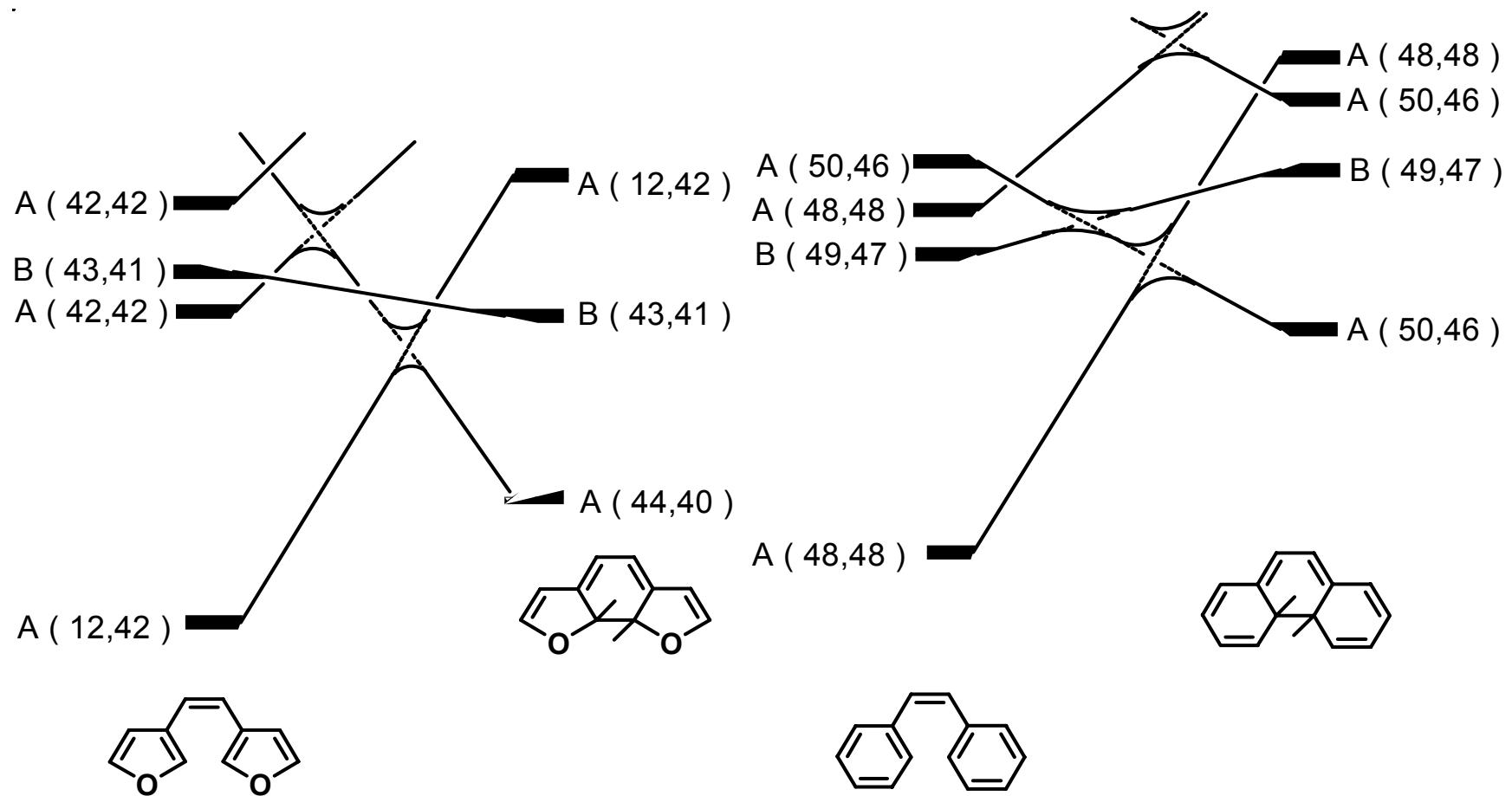
- Thermal reaction - - - disrotatory mode



- Photochemical reaction - - - conrotatory mode

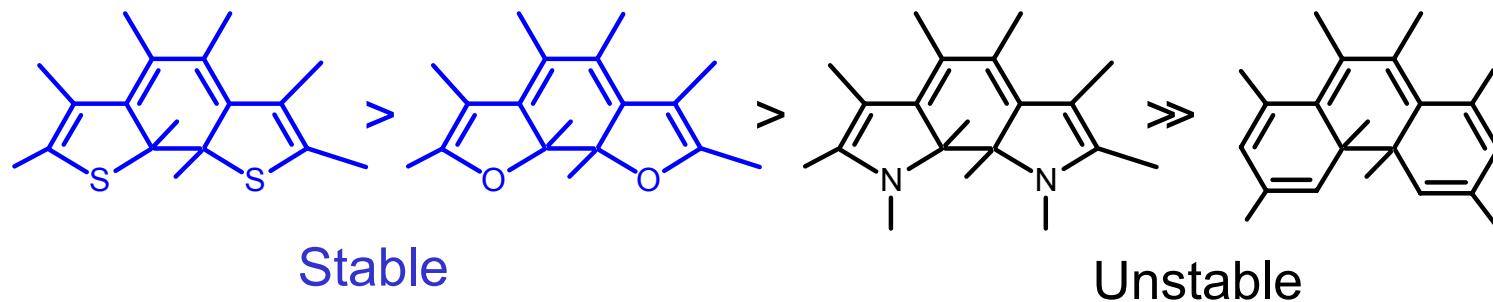


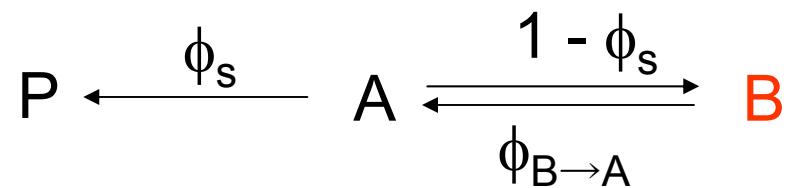
## Conrotatory Mode - - - Photochemical Reaction Process



## Molecular Design Principle —Thermal Irreversibility—

“ When the compound has aryl groups with low aromatic stabilization energy, both isomers of the diarylethene are thermally stable.”





$$\phi_s = 0.001 \ (\phi_{\text{B} \rightarrow \text{A}} = 1)$$

After  $10^3$  cycles

$$[\text{A}] \sim 0.37 [\text{A}]_0$$

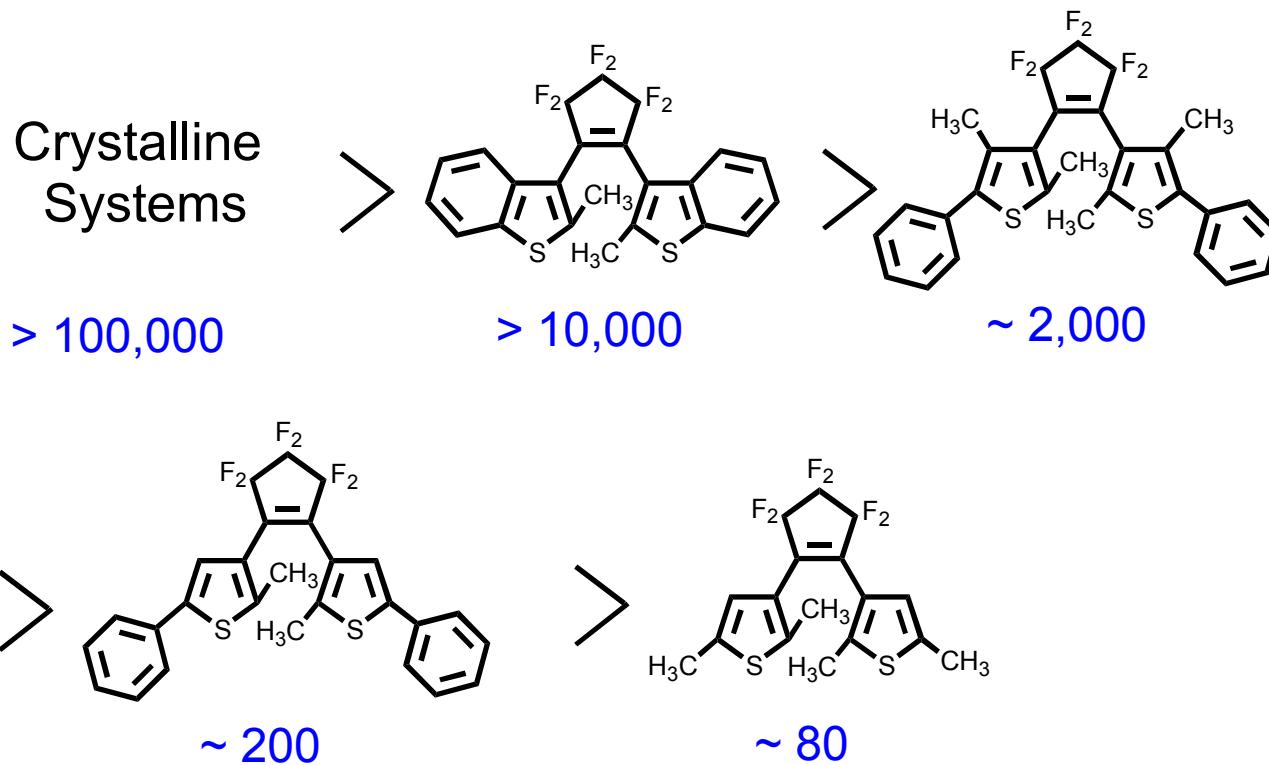
$$\phi_s = 0.0001 \ (\phi_{\text{B} \rightarrow \text{A}} = 1)$$

After  $10^4$  cycles

$$[\text{A}] \sim 0.37 [\text{A}]_0$$

# Molecular Design Principle

## — Fatigue Resistant Character —

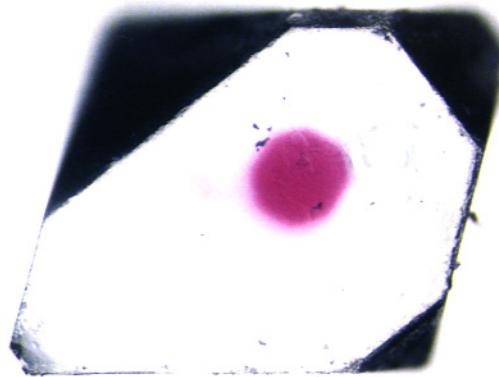




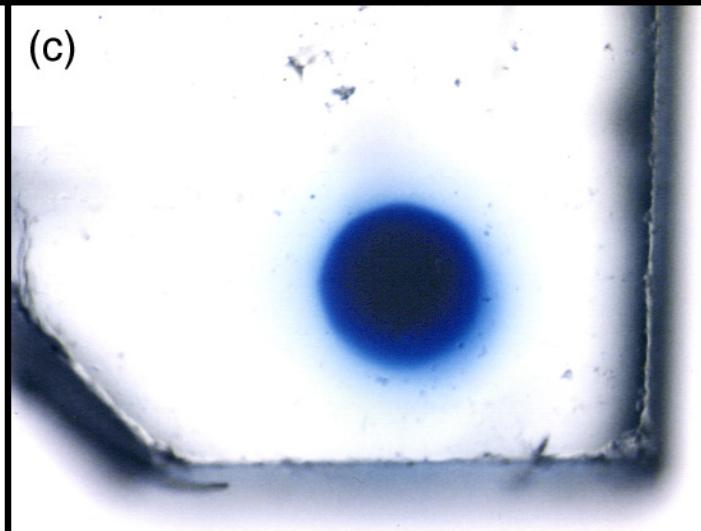
UV  
↔  
Vis.



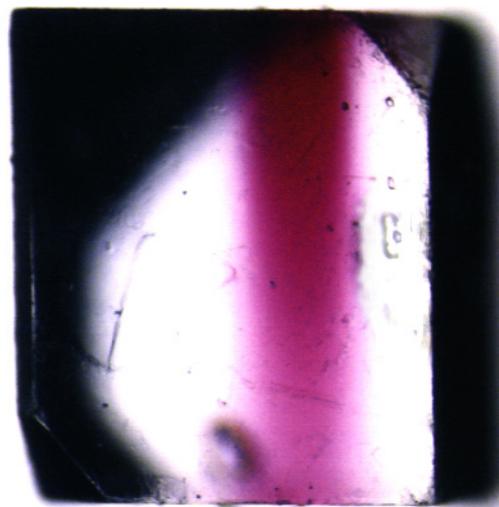
(a)



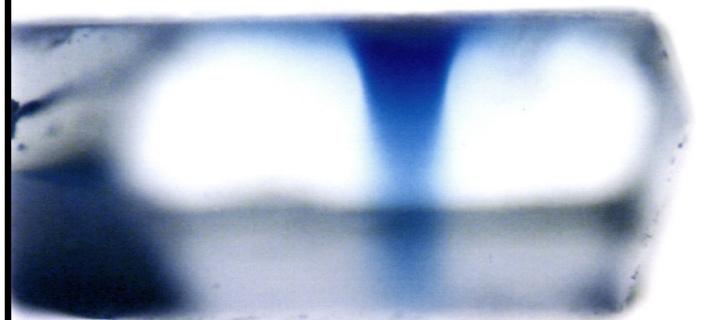
(c)



(b)



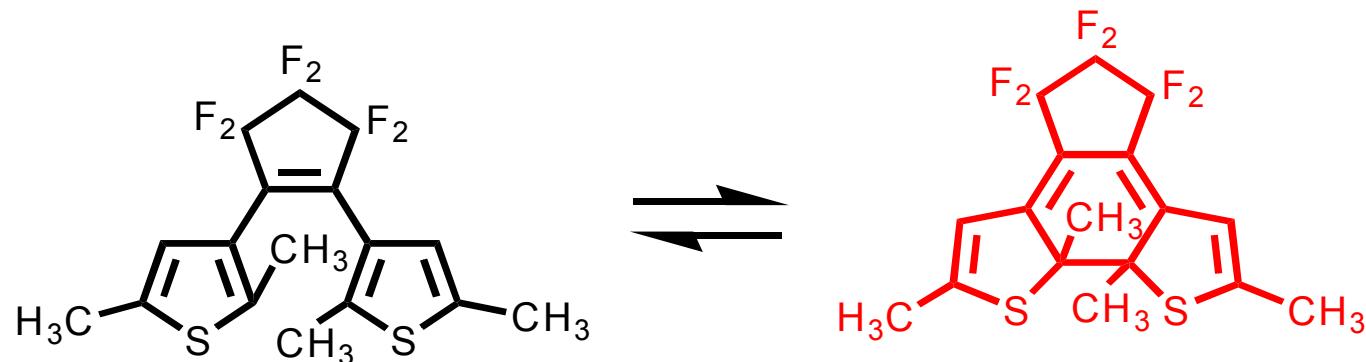
(d)



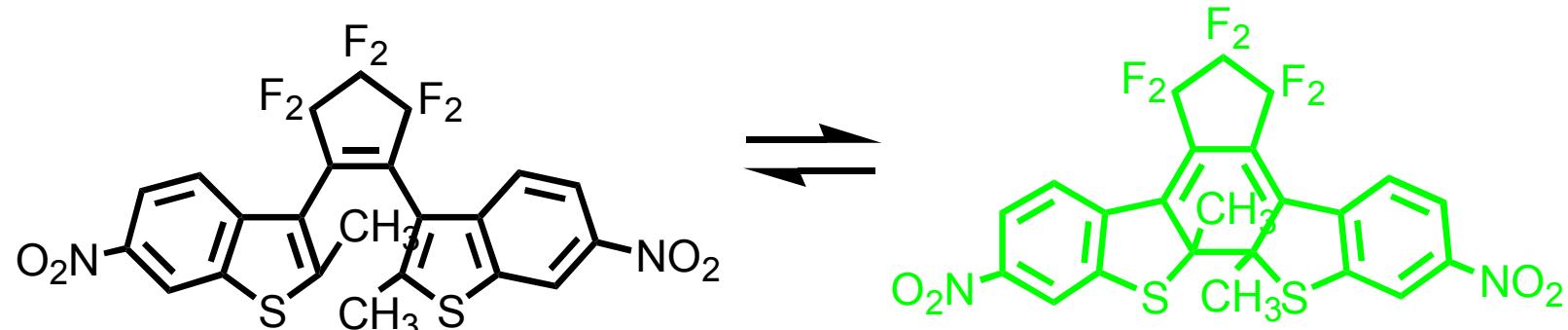
1.0 mm

0.5 mm

# Dichroism

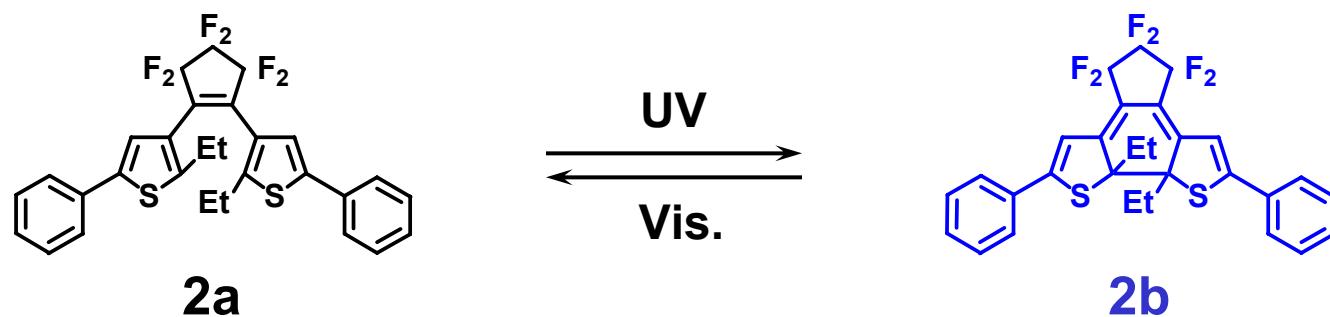
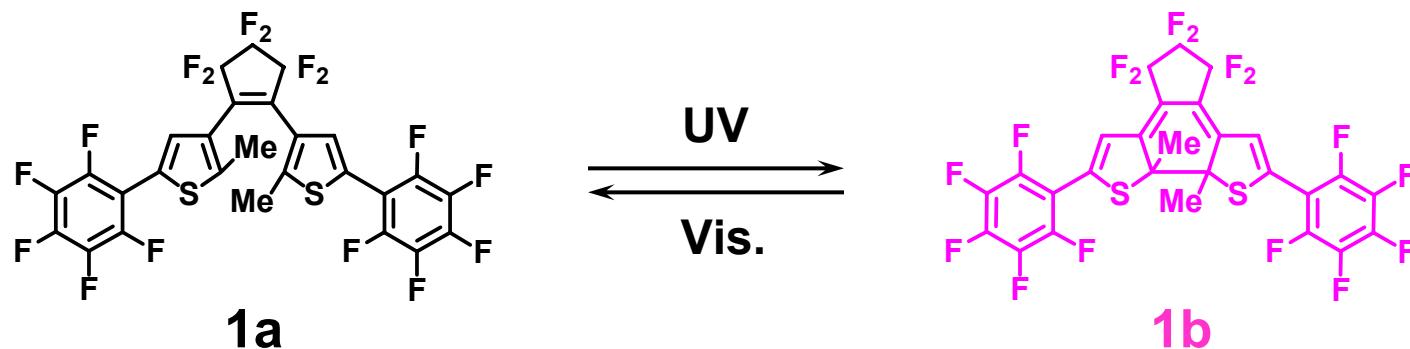


*J. Am. Chem. Soc.* **121**, 2380 (1999)



*J. Am. Chem. Soc.* **121**, 8450 (1999)

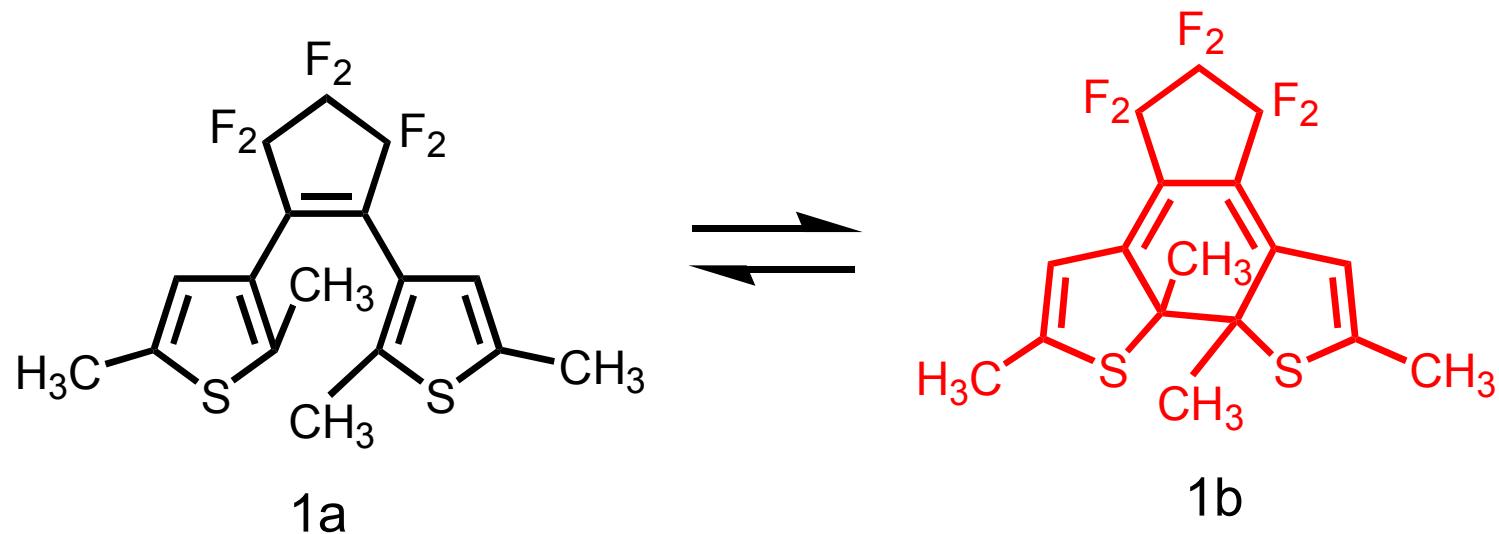
# Nano-layered Structure



*Photochem. Photobio. Sci.* 2, 1088 (2003)

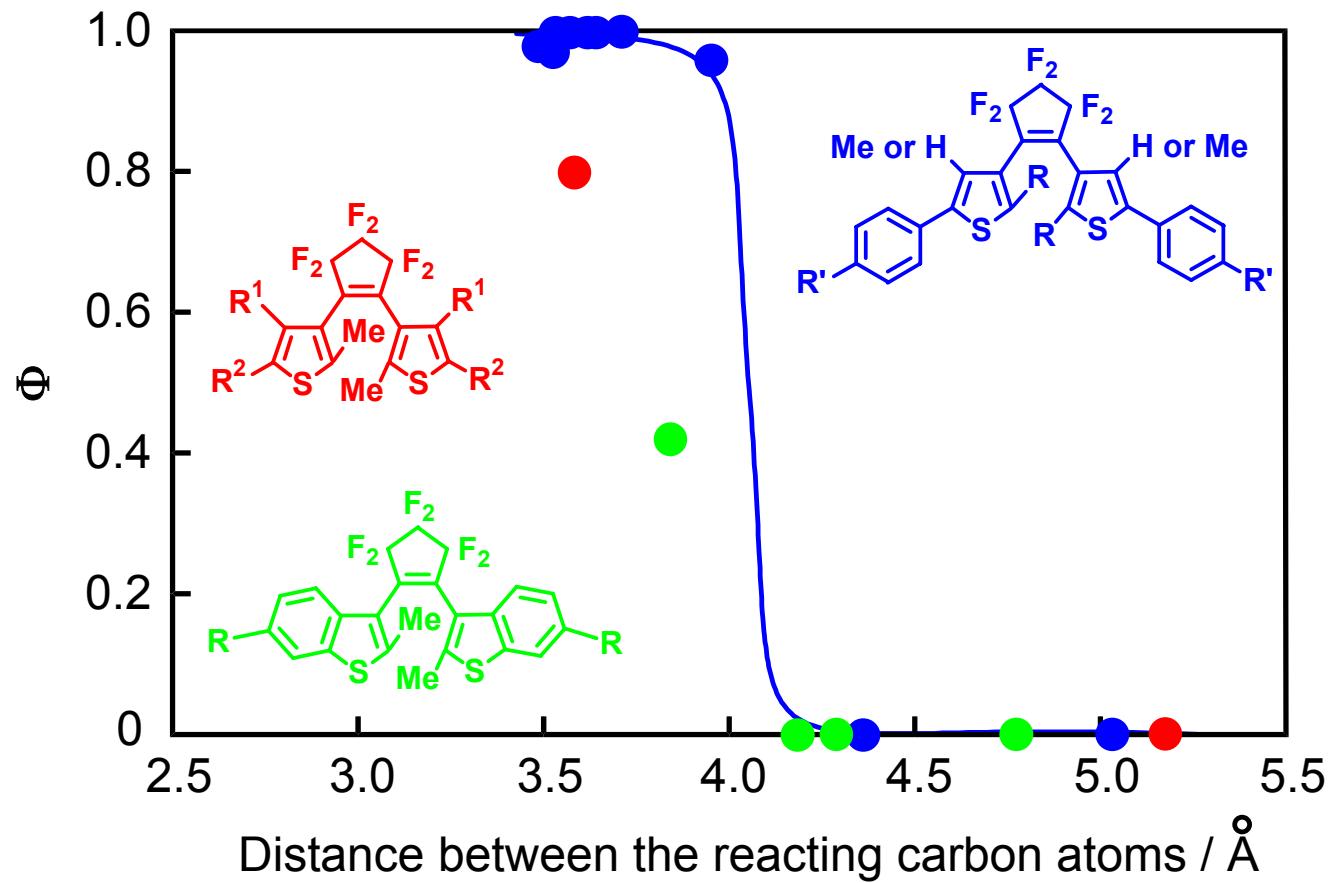
*Chem. Rec.* 4, 23 (2004)

# X-ray Crystallographic Analysis



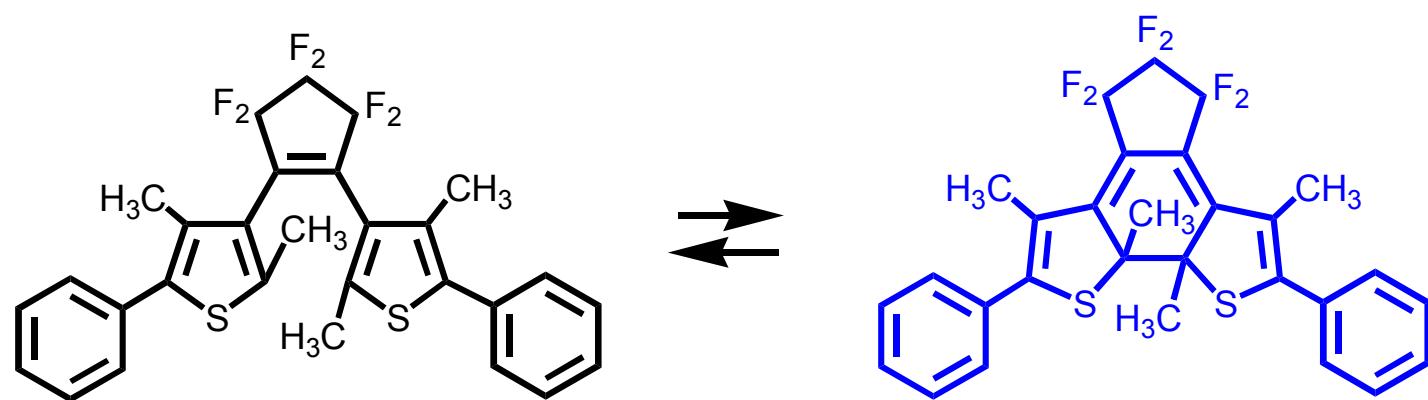
*J. Am. Chem. Soc.* **122**, 1589 (2000)

*Bull. Chem. Soc. Jpn.* **73**, 2179 (2000)

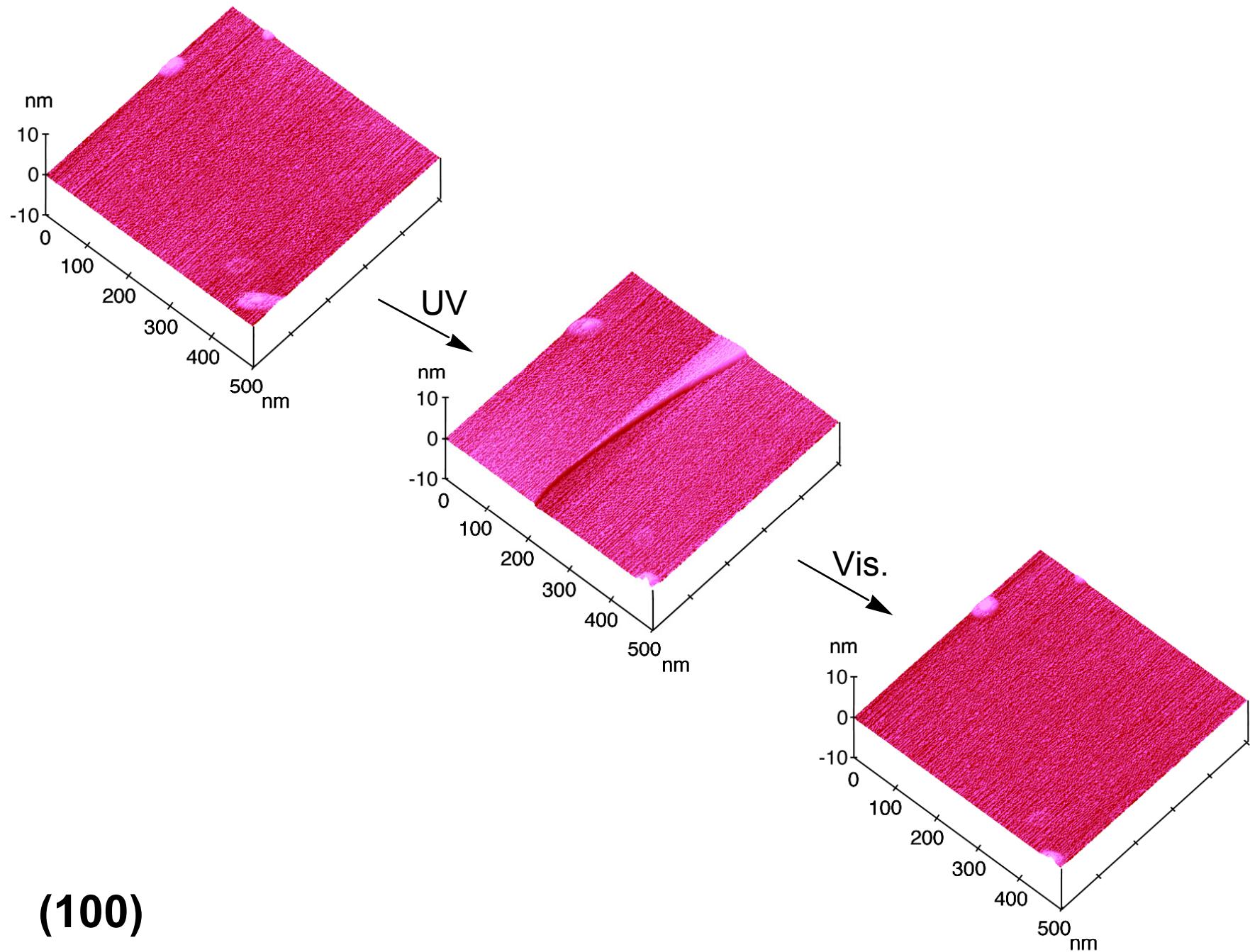


*J. Phys. Chem. A. 106, 209 (2002)*  
*Chem. Commun. 2804 (2002)*

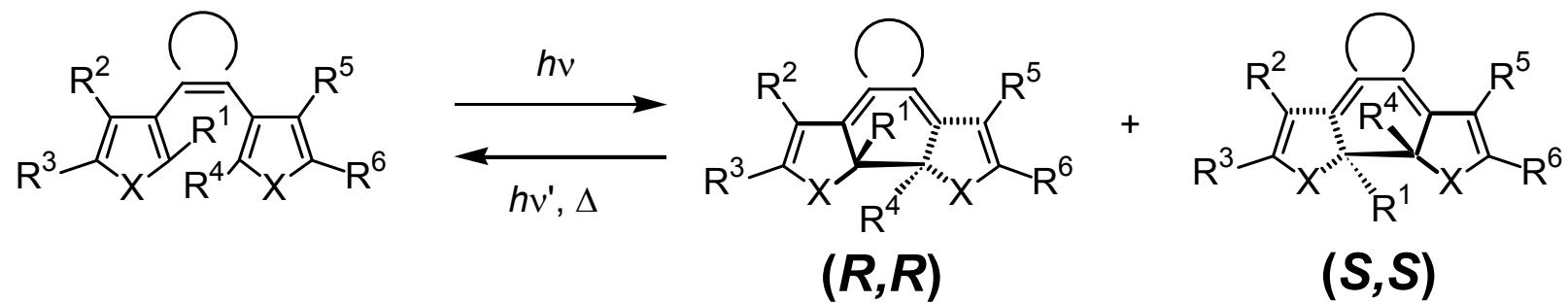
# Surface Morphology Changes of Single Crystal 1



Science, 291, 1769 (2001)



# Absolute Asymmetric Photosynthesis



*Ang. Chem. 42, 1636 (2003)*

*Tetrahedron Lett. 42, 7291 (2001)*

*J. Am. Chem. Soc. 122, 9631 (2000)*